



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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#6 / Bw /
3/4/03
Draining
Changes
John H

In re Application of:

Kar Roy et al.

Serial No.: 10/073,751

Filed: February 9, 2002

For: **Method For Fabricating A Metal
Resistor In An IC Chip And Related
Structure**

Art Unit: 2815

Examiner: Chu, Chris C

AMENDMENT AND RESPONSE TO OFFICE ACTION

Honorable Commissioner of
Patents and Trademarks
Washington, D.C. 20231

Dear Sir:

This is in response to the Office Action dated October 25, 2002 in the above-referenced patent application. Please enter and consider the following amendments and remarks.

02/25/2003 HVUONG1 00000011 10073751

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